

EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

NEC 1030

Application Number

09/273,627

Applicant(s)

UENO

Filing Date

03/23/1999

Group Art Unit

1762

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
MG		4-320325	11/11/1992	JAPAN	H01L	21/205		✓
MG		9-223672	08/26/1997	JAPAN	H01L	21/205		✓
MG		6-283440	10/07/1994	JAPAN	H01L	21/205		✓

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

MG		57-39431	Publicaiton of Japanses Laid-Open Patent	IPC 7th Edition	H01L	date unknown

EXAMINER

Yana Guevra

DATE CONSIDERED

7-13-04

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>	Docket Number (Optional)	Application Number
	NEC 1030	09/273,627
	Applicant(s) UENO	
	Filing Date	Group Art Unit
	MARCH 23, 1999	1762

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
MG		3-8333	1/16/91	JAPAN	H01L	21/31		✓

OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*

EXAMINER <i>Yara Guevara</i>	DATE CONSIDERED <i>7-13-04</i>
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